



Characterisation of a Cu selective resin for use in the production of Cu isotopes



Outline

- Resin characterisation
 - Selectivity
 - Interferences with Ni or Zn
- Column Experiments
 - Optimisation
 - Simulated targets
 - Decontamination factors
- Conversion of Cu resin eluate via AIX
- Other applications



D_w Cu resin in HCl

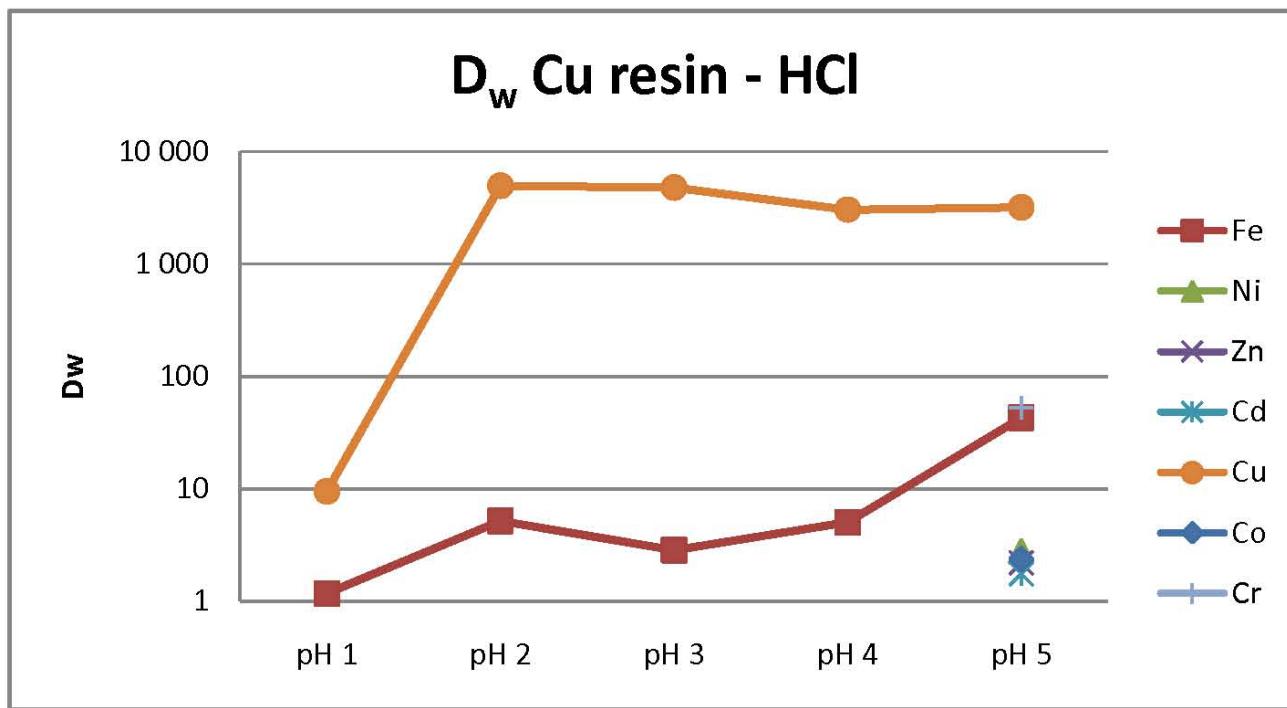


Figure 1: D_w of Cu and selected elements on Cu resin in HCl, varying pH values, measurement via ICP-MS, each element 10 μ g/ml

Loading conditions (> pH 2):

- Good selectivity for Cu over other elements tested,
- Some selectivity for Fe at high pH

Elution:

- Low Cu D_w at low pH, further tests with 4, 6 and 8 M HCl

D_w Cu resin in HNO_3

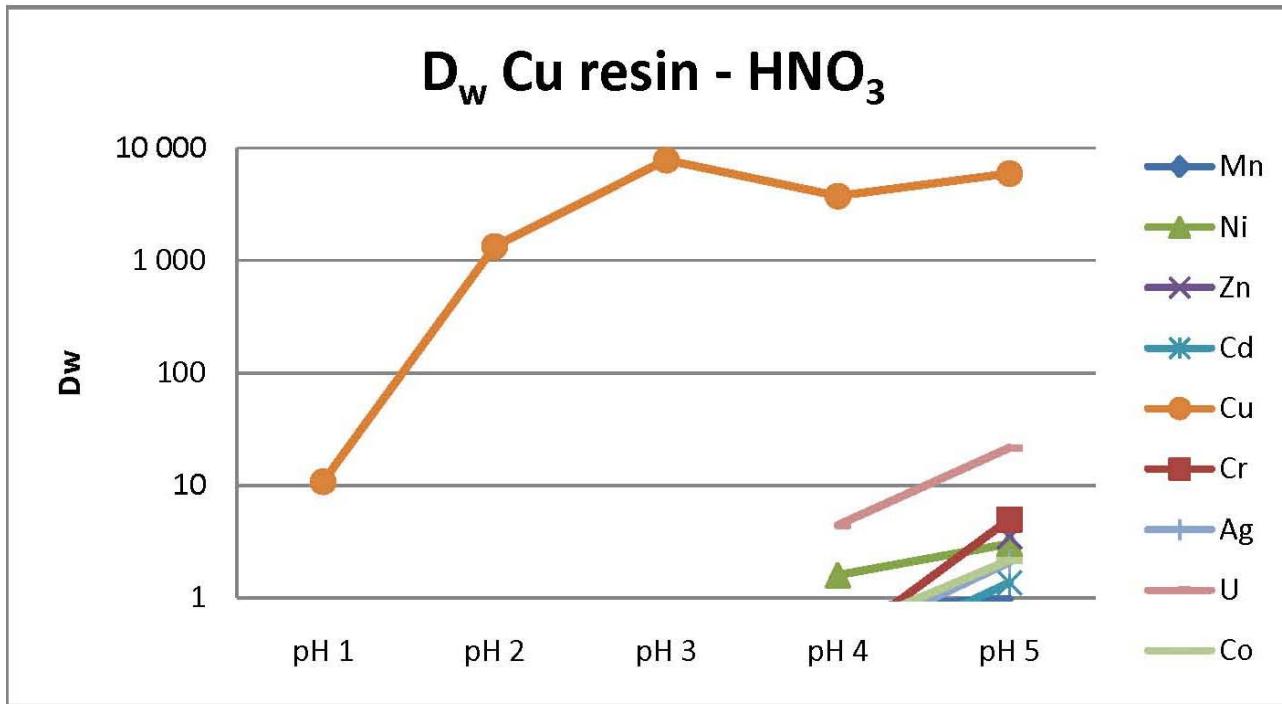


Figure 2: D_w of Cu and selected elements on Cu resin in HNO_3 , varying pH values, measurement via ICP-MS, each element 10 $\mu\text{g}/\text{ml}$

Loading conditions (> pH 2):

- Good selectivity for Cu over all other elements tested

Elution:

- Low Cu D_w at low pH

D_w Cu resin in H_2SO_4

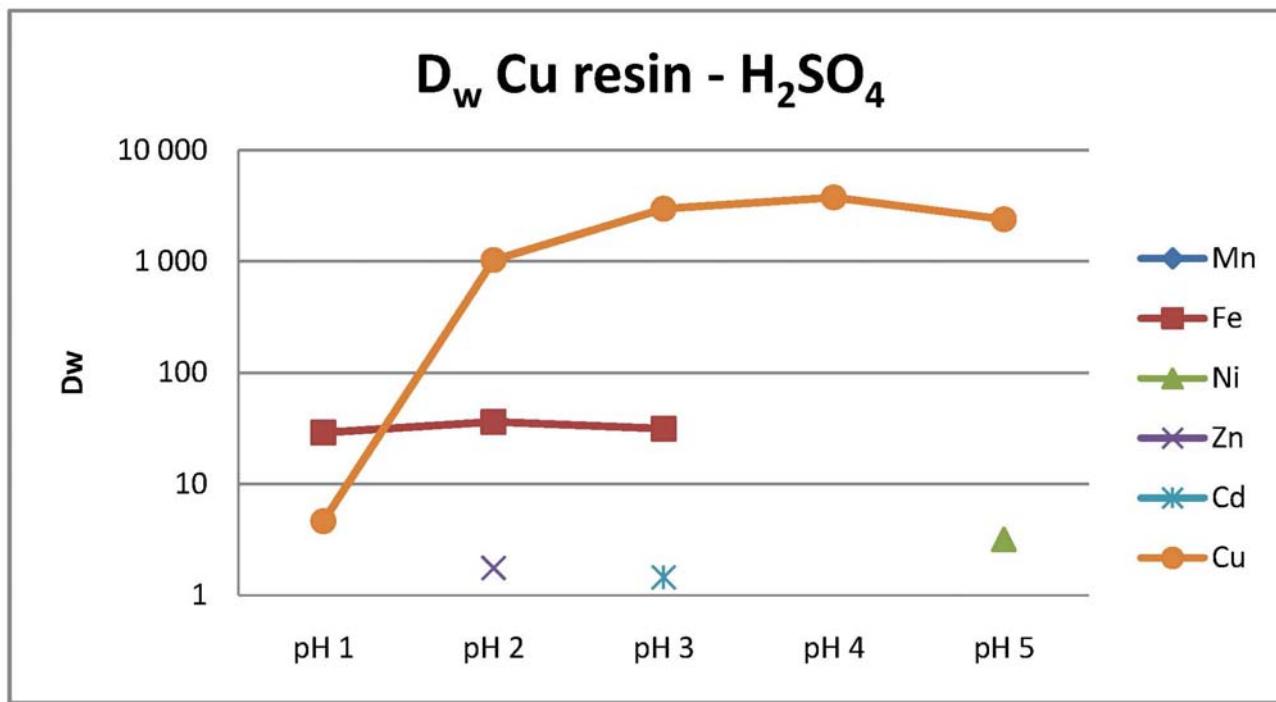


Figure 3: D_w of Cu and selected elements on Cu resin in H_2SO_4 , varying pH values, measurement via ICP-MS, each element 10 μ g/ml

Loading conditions (> pH 2):

- Good selectivity for Cu over most other elements tested
- Limited selectivity for Fe

Elution:

- Low Cu D_w at low pH

D_w Cu – interferences - HCl pH 2

Ni interference

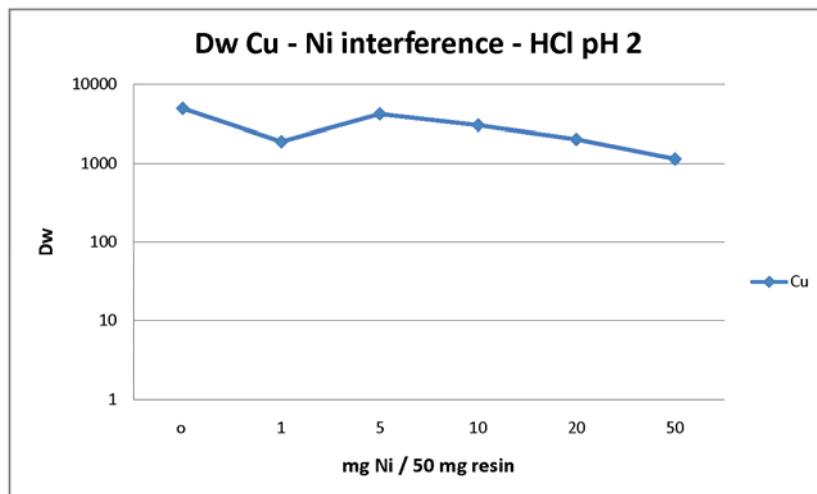


Figure 4: D_w of Cu on Cu resin in HCl (pH 2) in presence of various amounts of Ni

Zn interference

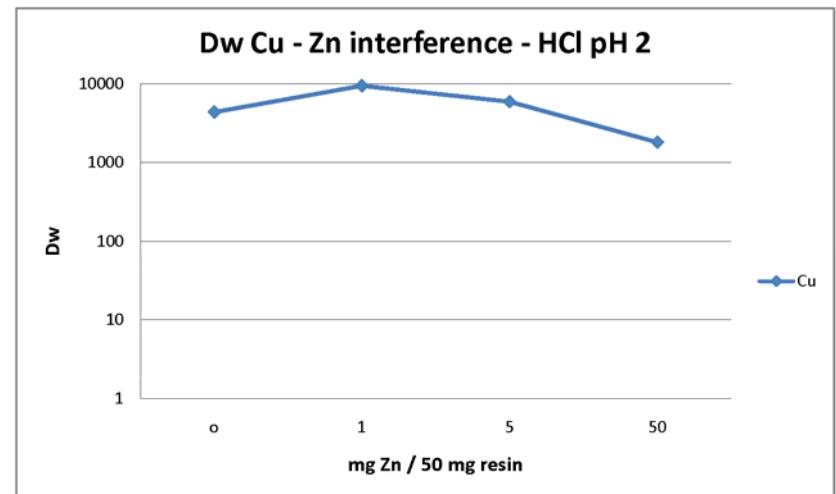


Figure 5: D_w of Cu on Cu resin in HCl (pH 2) in presence of various amounts of Zn

- For high amounts of Ni or Zn D_w (Cu) remains > 1000 in pH 2 HCl
- For up to 1 g target material per g resin only negligible interference

Conclusions I

- Stable, high Cu D_w values at pH > 2 for all acids
- Good selectivity for Cu over tested elements
- No selectivity for Zn or Ni
- No interference on Cu extraction by elevated amounts of Ni or Zn
 - Tested up to 1g Ni or Zn per g of resin
- HCl system chosen for radiopharmaceutical application
 - Loading solution: HCl pH 2 (or higher)
 - Elution with HCl (elevated concentration)

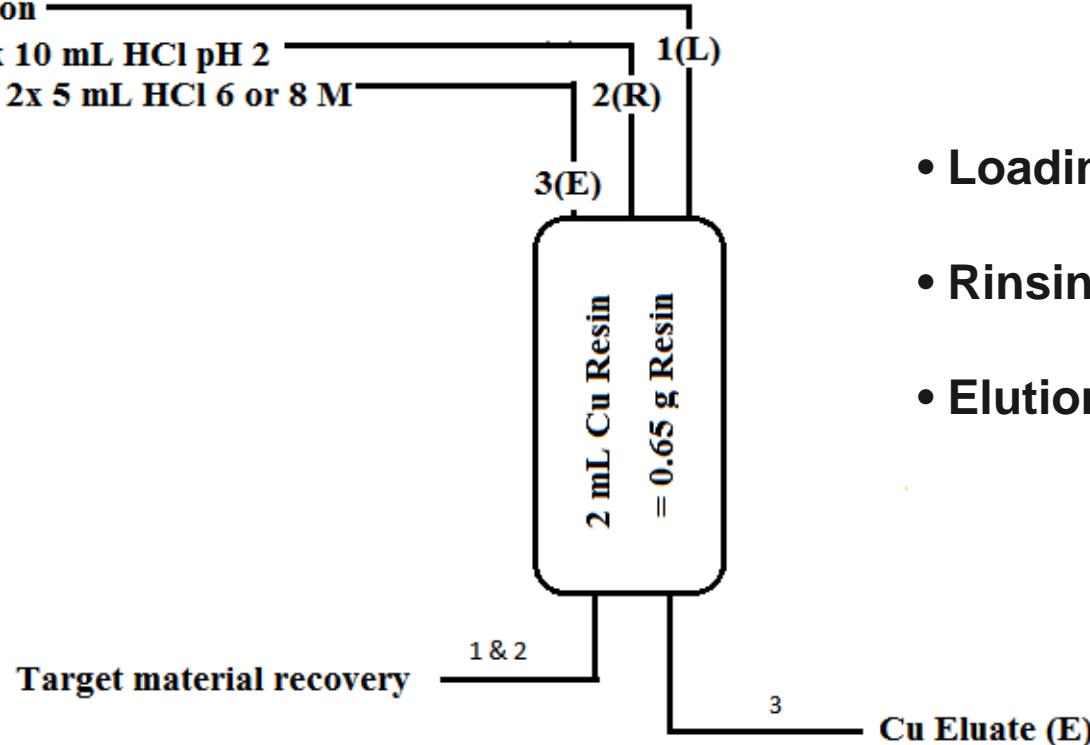


First approach

Loading : 5 mL simulated or dissolved irradiated target solution

Rinsing : 2 x 10 mL HCl pH 2

Elution Cu : 2x 5 mL HCl 6 or 8 M



- Loading : L1
- Rinsing : R1 & R2
- Elution : E1 & E2

Figure 6: Scheme of elution conditions – first approach

Elution study – 2 mL CU resin column

Elution with 6 M HCl

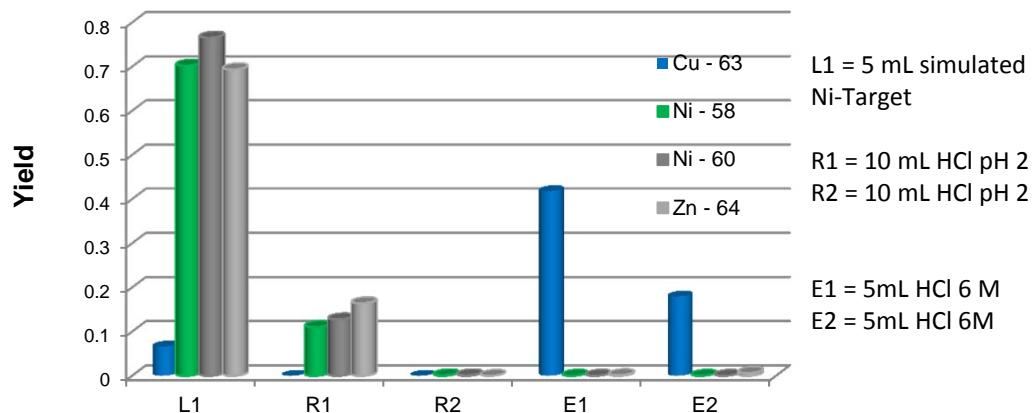
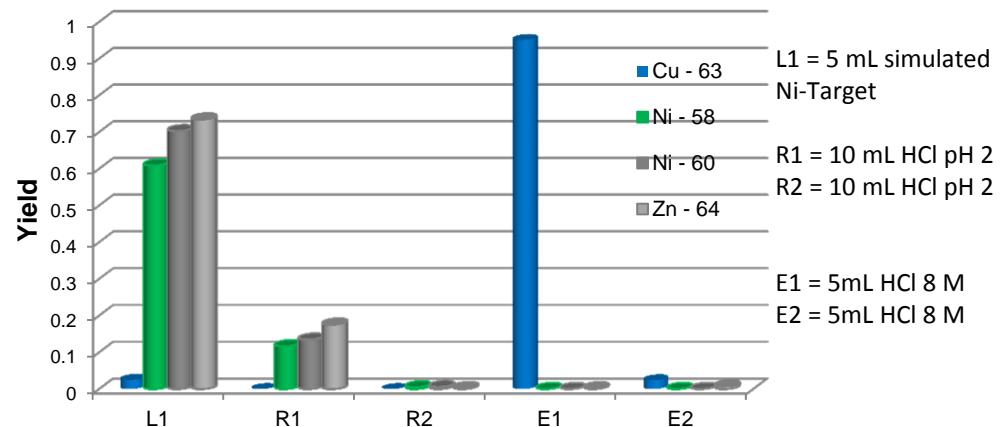


Figure 7/8 : Elution study; simulated Ni targets (200 mg Ni, traces of Zn, Cu), elution with 6M HCl and 8M HCl

Elution with 8 M HCl

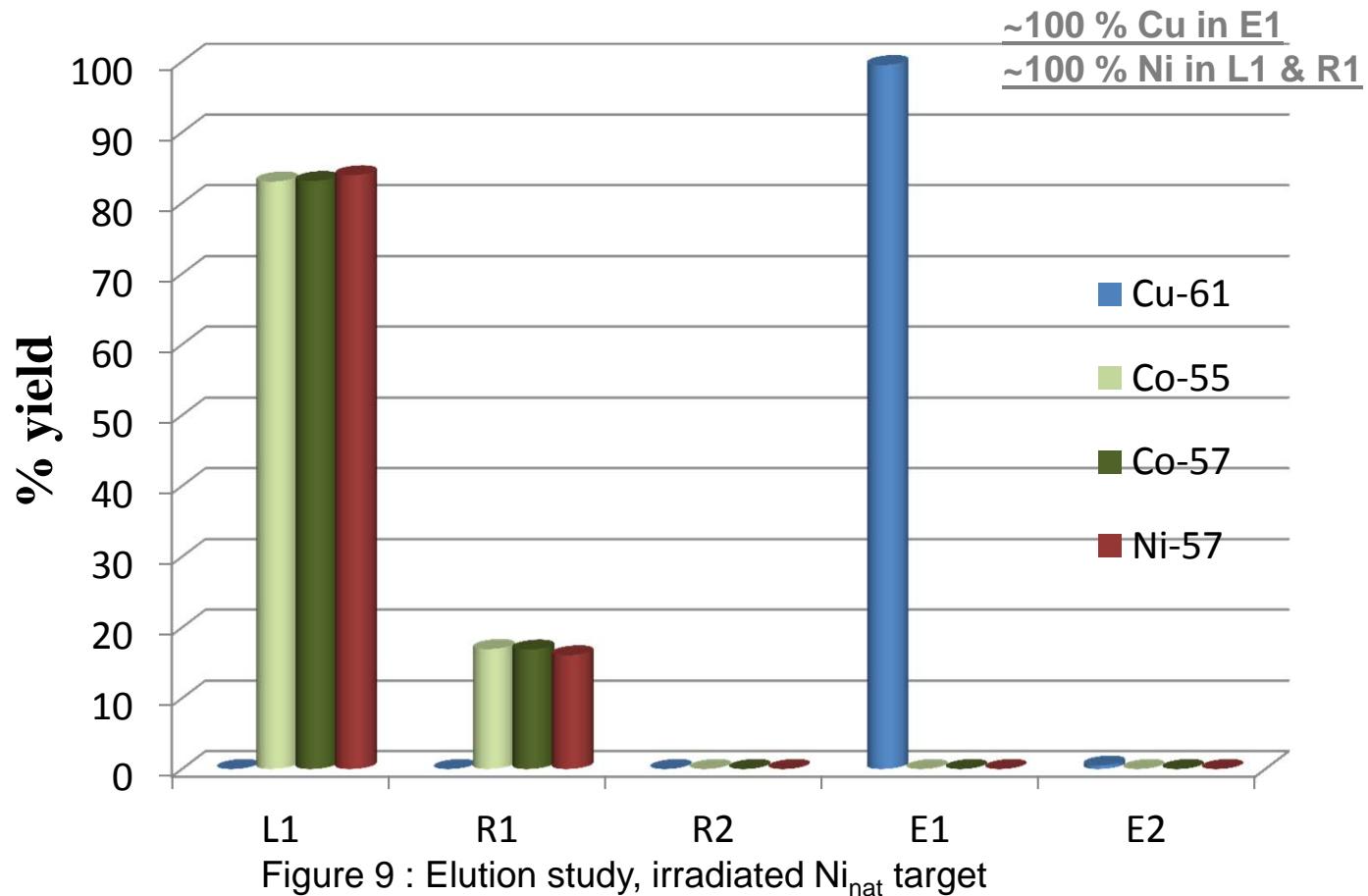


- 8M HCl allows for elution in smaller volume
- Clean Cu fraction

Elution study - irradiated Ni target

- Irradiation of a Ni foil (10 mg) :
 - ($\varnothing = 13 \text{ mm}$, 0.025 mm thickness)
 - Cyclotron BC1710 at Forschungs Zentrum Jülich
 - $E_p = 15 \text{ MeV}$
 - 1 h; 0.5 mA
- Additionally 170 mg non-irradiated Ni-foil added

Elution study – irradiated Ni target



Loading:

L1 : 5 mL HCl pH 2

Rinsing:

R1 : 10 mL HCl pH 2

R2 : 10 mL HCl pH 2

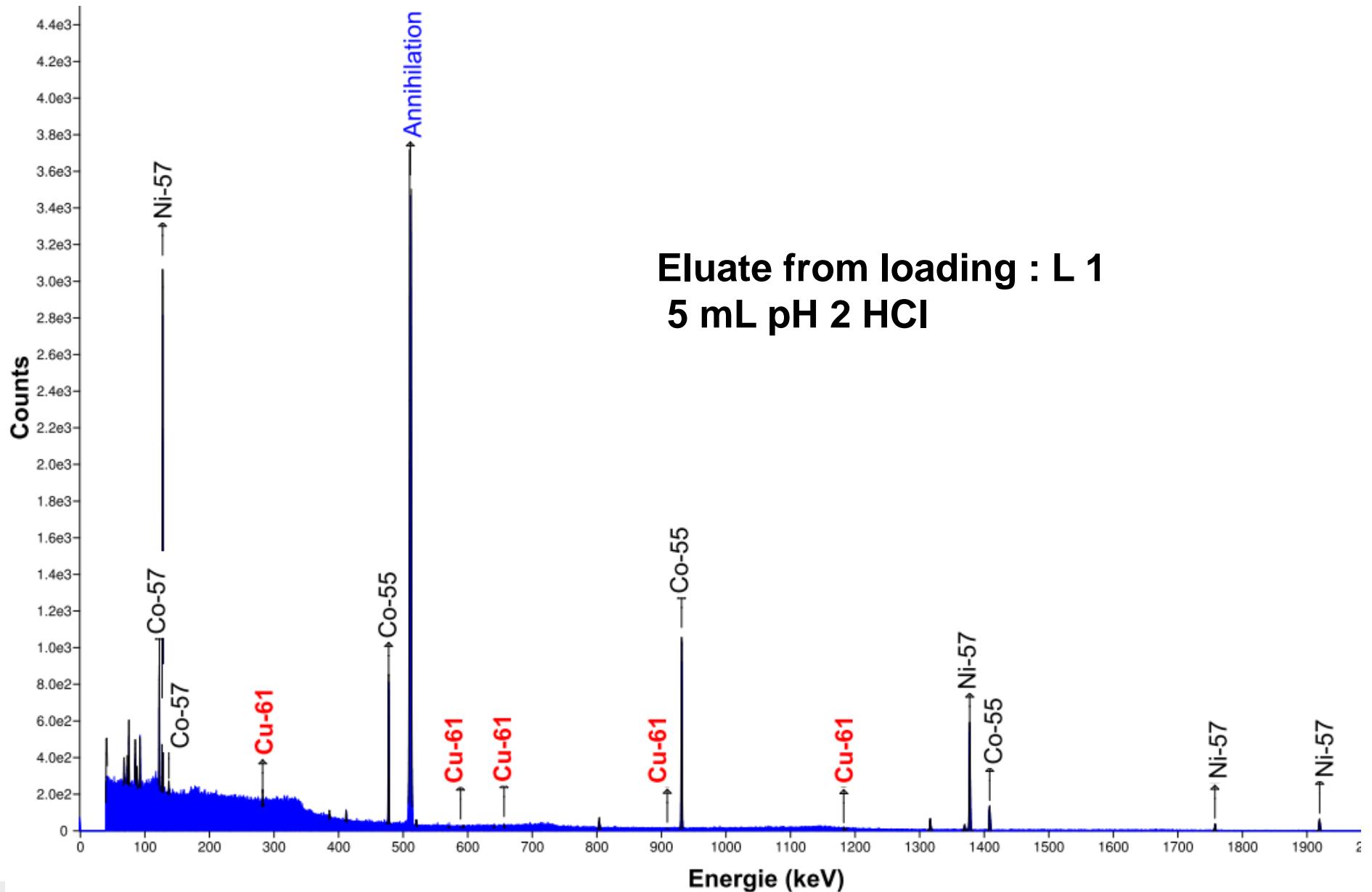
Elution:

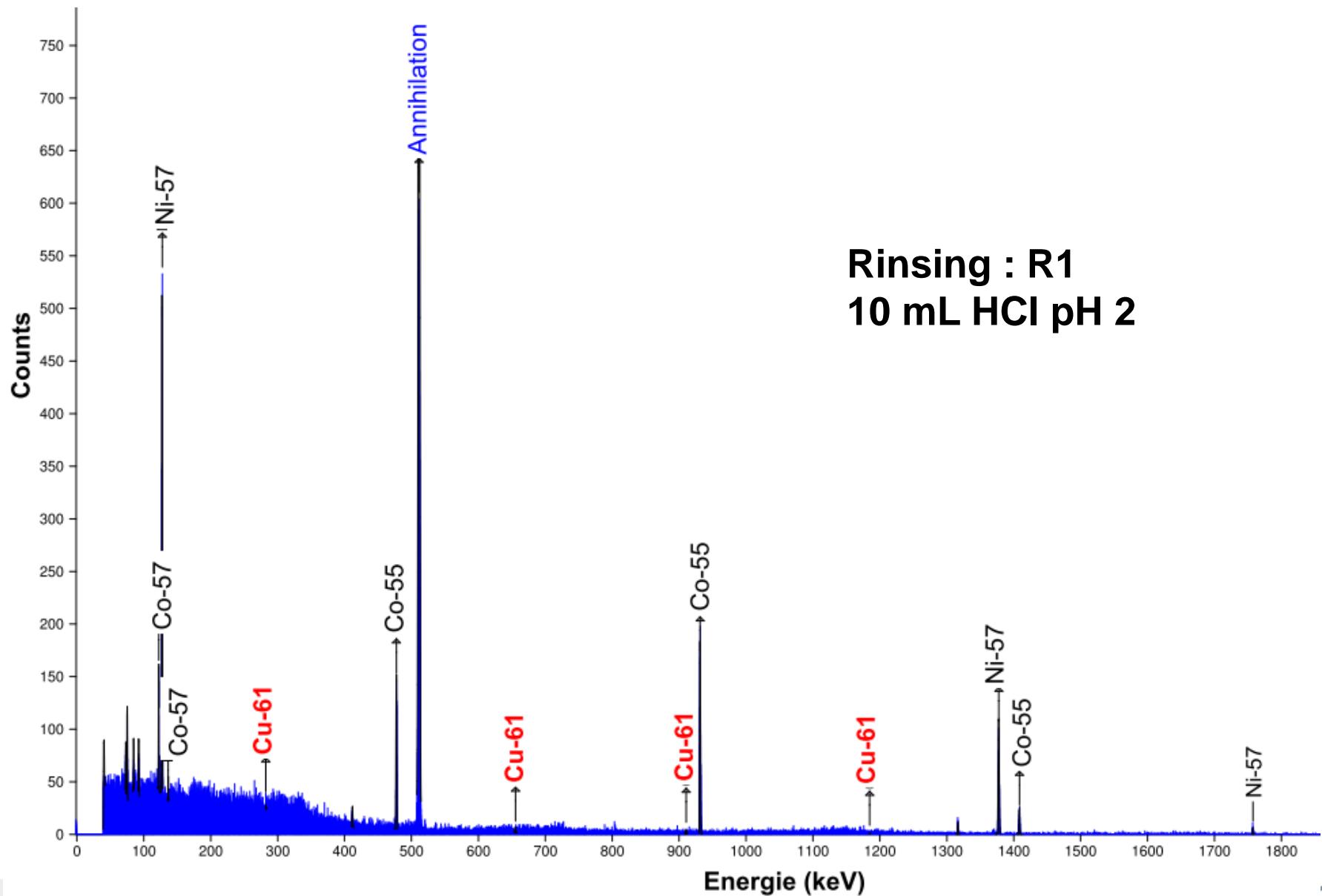
E1 : 5 mL HCl **8 M**

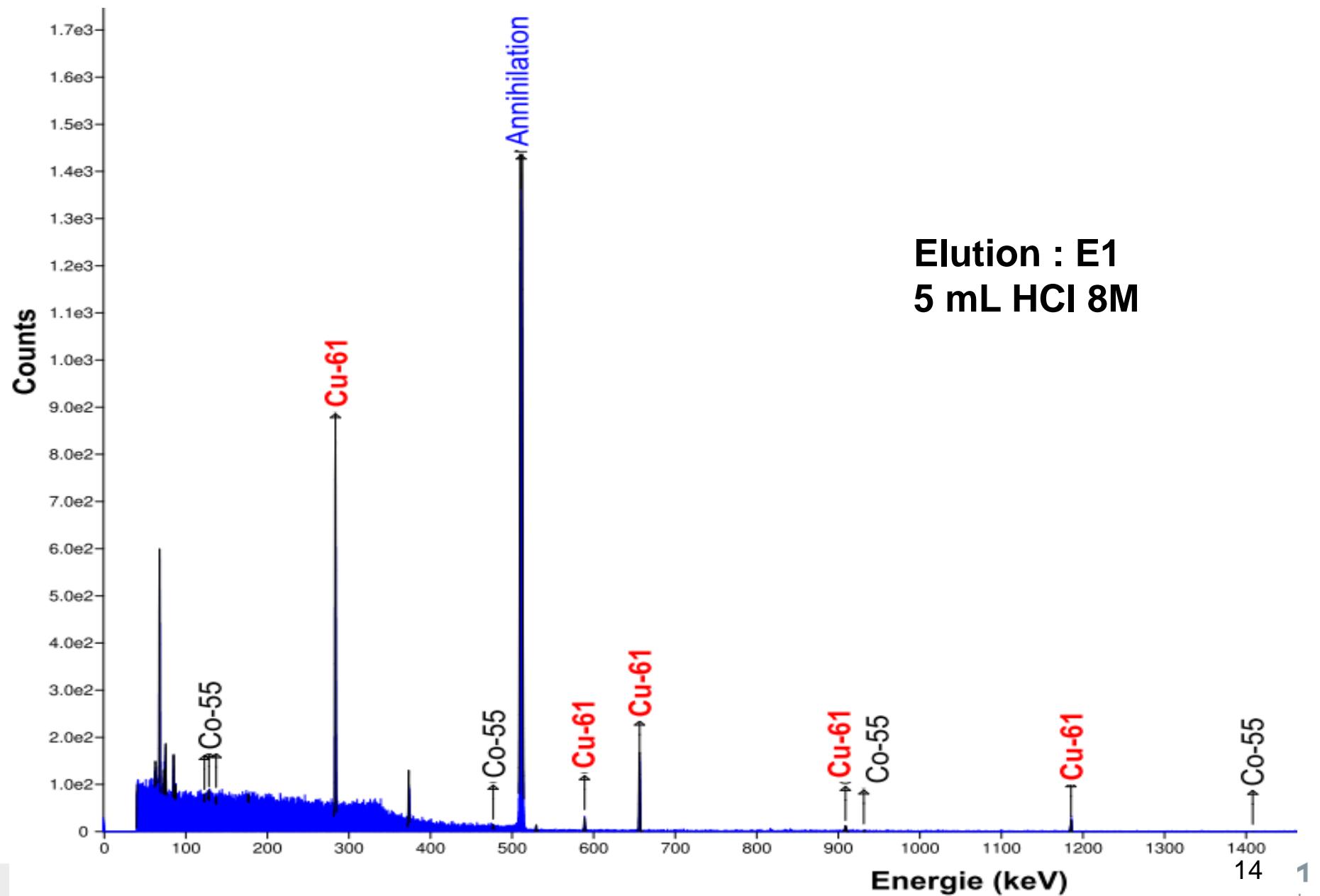
E2 : 5 mL HCl **8 M**



- Very pure Cu fraction
- Elution and rinsing volumes to be optimized







Optimization of Cu elution volume

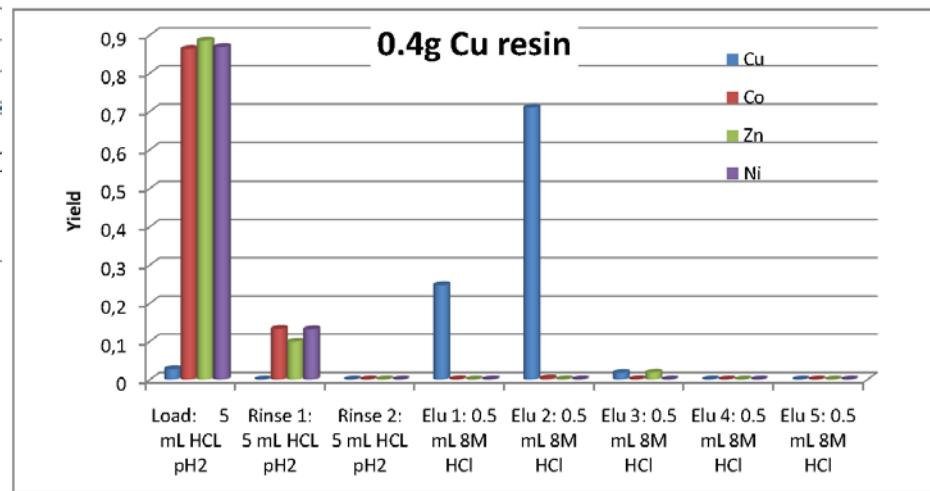
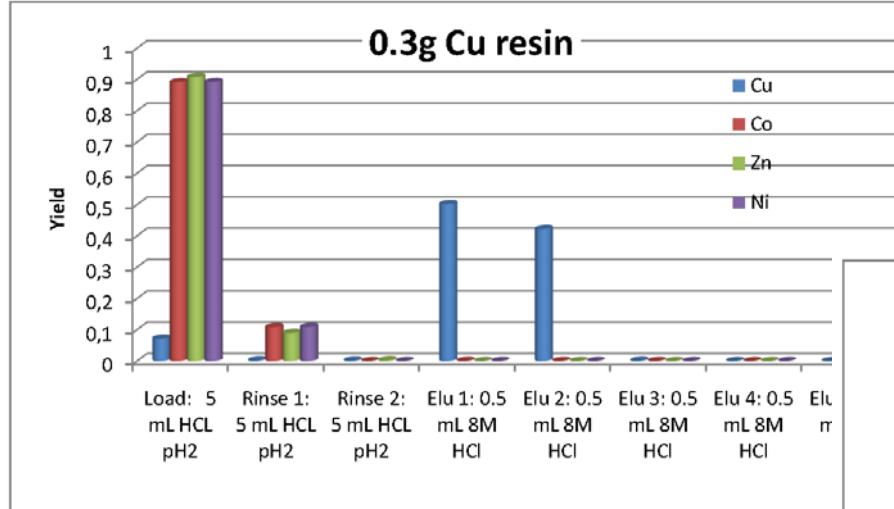
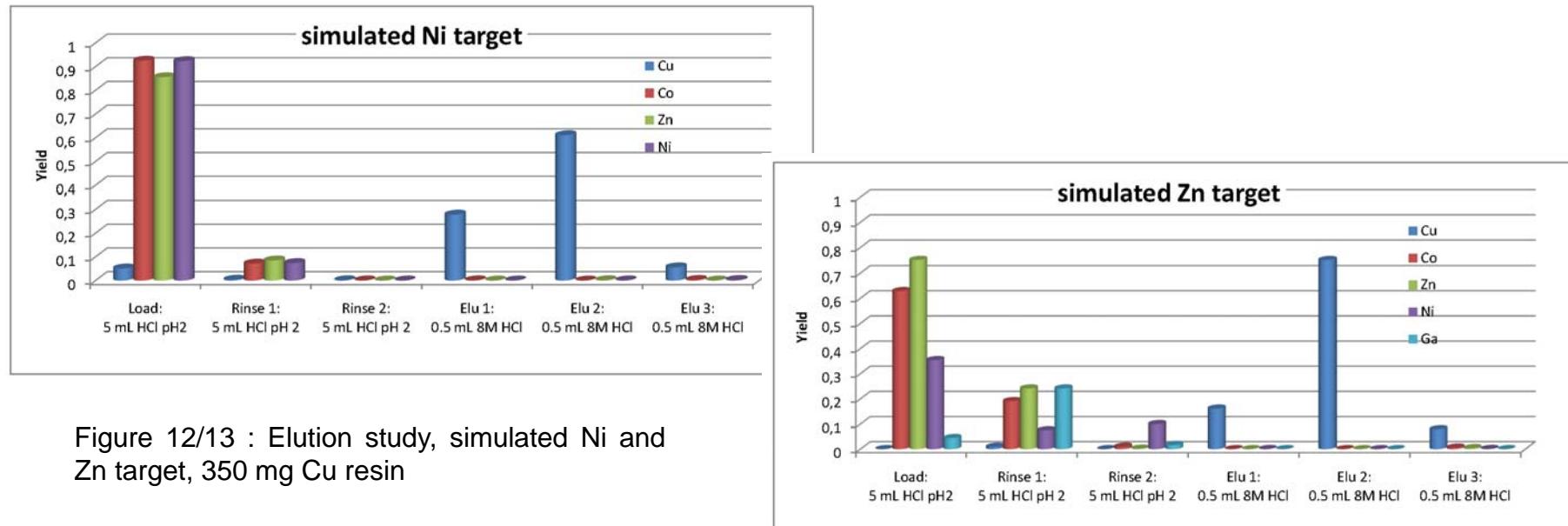


Figure 10/11: Elution study, simulated Ni target, varying Cu resin amounts, gravity flow

- Use of smaller columns allows reducing Cu elution volume
 - Near quantitative Cu recovery in ~1 mL 8M HCl
- No impact on Cu purity

Optimization of Cu elution volume – vacuum-assisted flow



- Flow rate: 1 mL/min (rinsing up to 6 mL/min)
- 0.35g CU resin columns
- > 90% recovery in 1 mL 8M HCl, quantitative recovery in 1.5 mL
- Simulated Ni and Zn targets (200 mg target material)
- No impact on purity

Optimized method

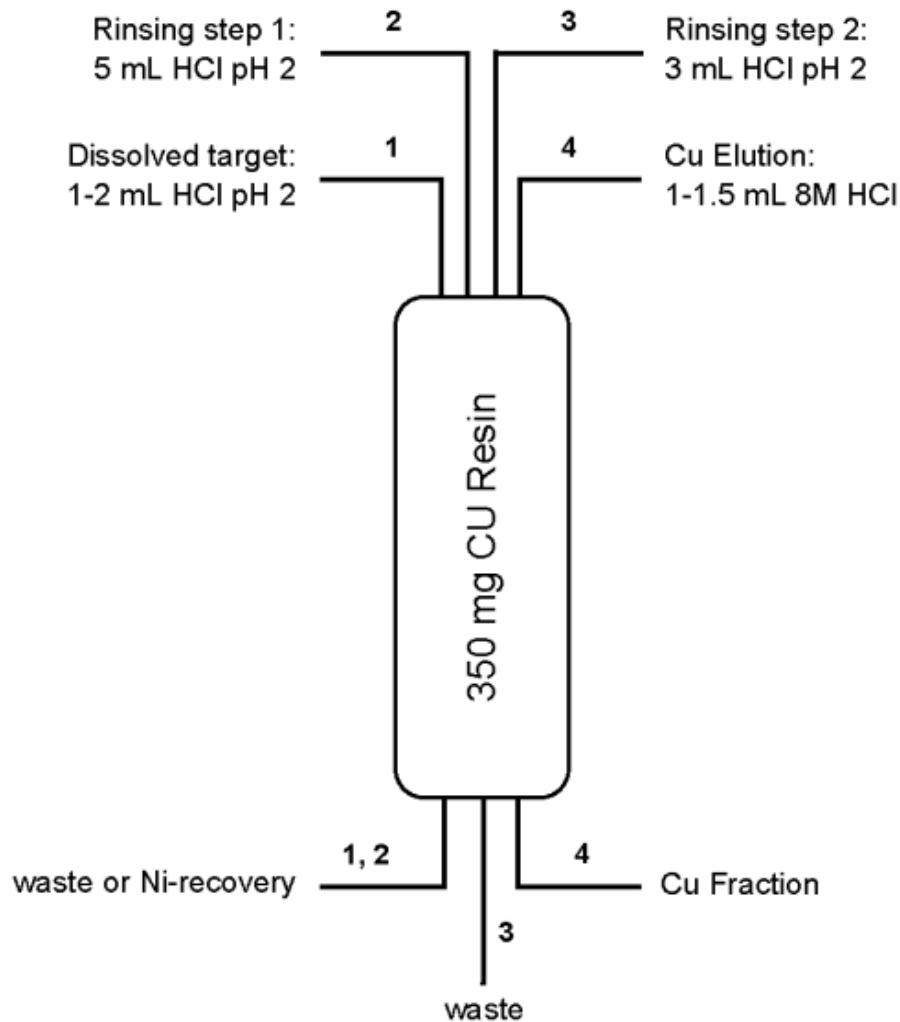


Figure 14: Scheme of elution conditions – optimized method

Decontamination factors D_f

- Flow rate: 1 mL/min (rinsing 6 mL/min)
- 0.35 g columns
- Loading solution: Ni, Zn, Co, Ga and Au in 5 mL HCl pH 2
- Separation following optimized method
- ICP-MS measurement
- Calculation of deconfactors D_f for Cu fractions
 - Fraction E1 (0.5 mL 8M HCl):
 - D_f : Ni, Co & Zn > 20 000
 - D_f : Au & Ga > 10 000
 - Fraction E2 (0.5 mL 8M HCl):
 - D_f : Ni > 20 000, Co > 40 000, Zn > 70 000,
Au > 50 000, Ga > 10 000



Conclusion II

- 350 mg columns allow for Cu elution in small volume
- Vacuum assisted flow
- Rapid separation
- Quantitative recovery of Cu in 1 – 1,5 mL 8M HCl
 - Cu yield > 90% in 1 mL 8M HCl
 - $97,6\% \pm 2,3\%$ ($k = 1$, $N=25$) in 1.5 mL 8M HCl
- Pure Cu fraction
 - D_f (ICP-MS)
 - γ -spectrometry
- Obtained Cu suitable for labelling (ARRONAX)
- Ni recovered in small volume of 8M HCl
 - 10 – 13 mL load and rinse
 - Further purification for reuse e.g. via diect load on AIX



Conversion of Cu eluate

- Aim: recovery of Cu in small volume of dilute HCl, water or NaCl solution
- Anion exchange resins (AIX) shows necessary selectivity
- Cu eluate (1 – 1,5 mL 8M HCl) from Cu resin column directly loaded onto small AIX column
- Rinse with 8M HCl
- Elution with deion. water



Elution study - AIX

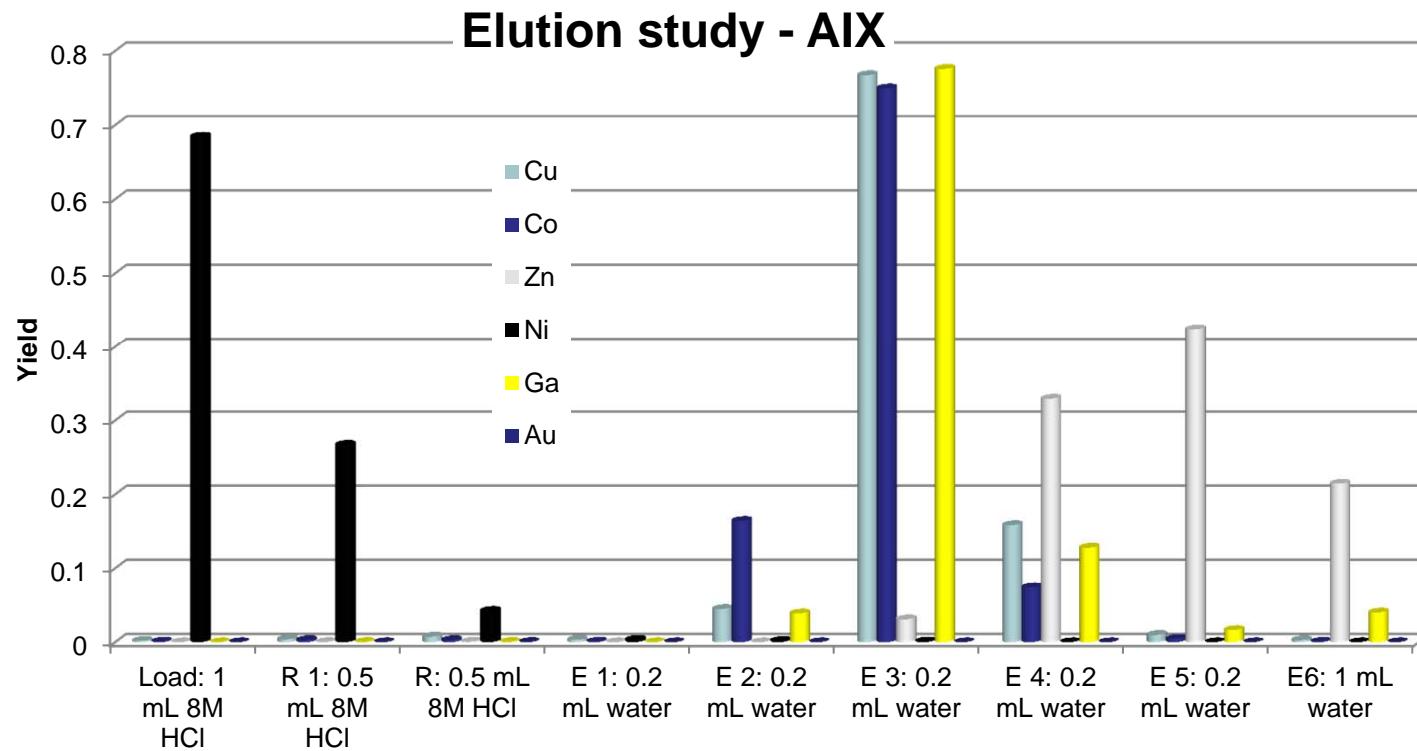


Figure 15: Elution study, AIX, various elements, 400 mg A8 Resin (200 – 400 mesh, Eichrom Technologies)

- 400 mg AIX (A8)
- Cu elution in 0.6 – 0.8 mL water
- Anion exchange conversion step gives additional decontamination from Ni, Zn, Au

Cu fraction conversion step

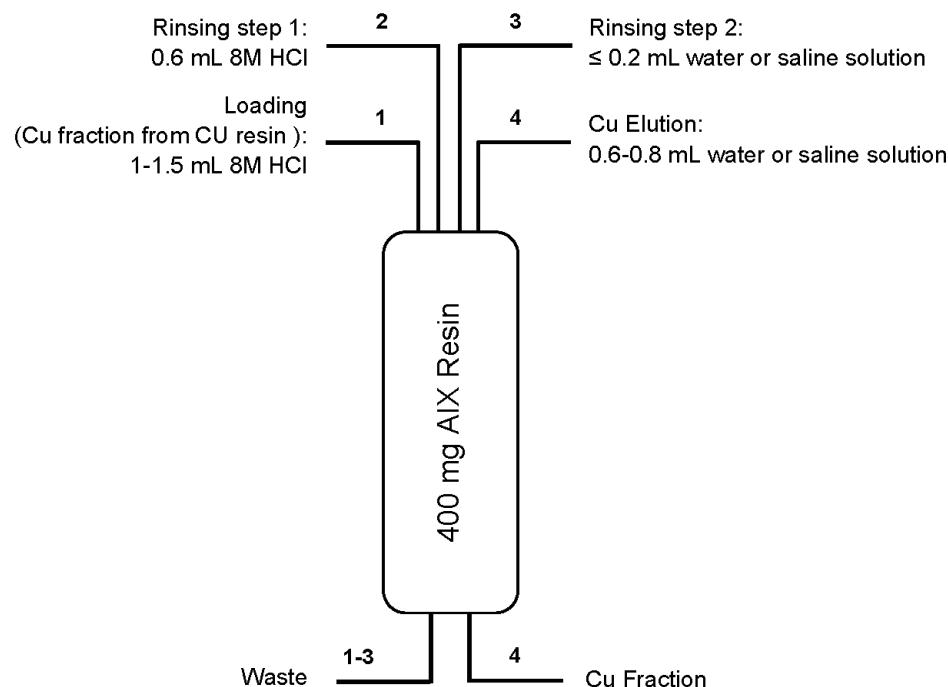


Fig 16: Conversion step using anion exchange, 400 mg A8 resin (Eichrom Technologies), 200 – 400 mesh

- Direct load of Cu eluate onto anion exchange resin / elution with water or saline solution
- Further purification from matrix elements and organics
- Cu yield in 0.7 mL water: $93,8 \pm 6,4\%$ ($k = 1$, $N=25$)

Full method

- Vacuum-assisted flow
- CU resin (350 mg)
 - Load from 1 - 2 mL HCl pH2
 - Rinse with 5 mL and 3 mL HCl pH 2
 - Load and rinse contain ~100% Ni (→ Ni-64 recovery)
 - Cu elution in 1 – 1.5 mL 8M HCl
- Cu yield > 95%; high decontamination factors
- Conversion on AIX (400 mg)
 - Load from 1 – 1.5 mL 8M HCl
 - Rinse with 0.6 mL 8M HCl and < 0.2 mL water
 - Cu elution in 0.6 – 0.8 mL water (or saline solution)
- Cu yield > 90%; add. decontamination (Ni, Zn, Au, organics)
- Overall separation time: <10 minutes



Other applications

- Removal of trace Cu-64 before Ni-64 plating
- Cu concentration and purification for analytical purpose (e.g. Cu in sea water)

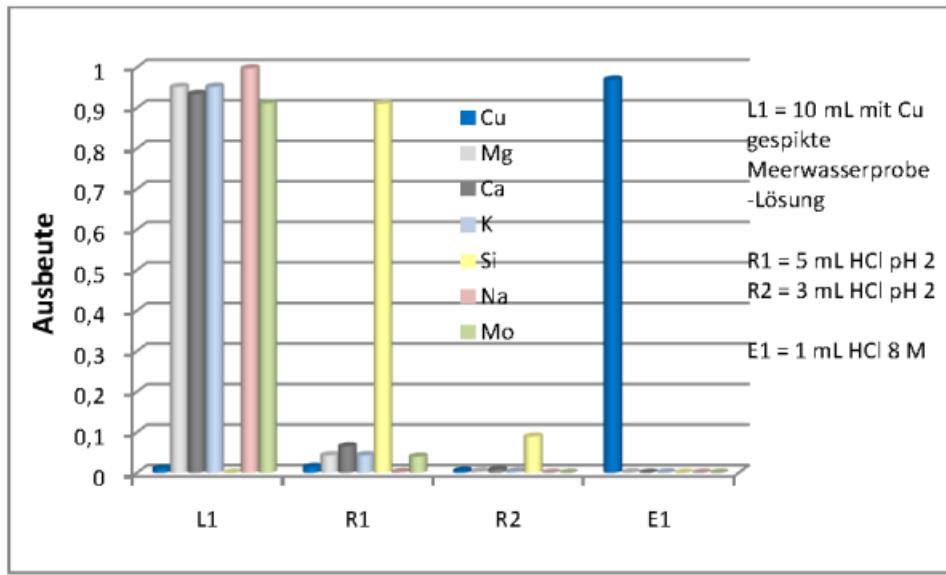


Fig 17: Elution study, 10 mL spiked sea water, 350 mg CU resin column, vacuum assisted flow

- 10 mL sea water (pH 2.3)
- Cu yield > 95% in 1 mL 8M HCl
- Pure Cu fraction